

IN THE CLAIMS:

Please substitute the following claims for the same numbered claims in the application:

Claim 1. (Currently Amended) An apparatus for holding a substrate, said apparatus comprising:

a pocket adapted to hold said substrate, wherein said pocket ~~has~~ comprises an inner edge and a lower surface; ~~and~~

a plurality of projections extending radially inward from said inner edge[[,]];

an opening in said lower surface; and

a pin disposed in said opening, said pin being configured for lifting said substrate from said pocket;

wherein said projections have a beveled edge, such that an acute angle occurs between said lower surface and said beveled edge, and

wherein said projections reduce an area of contact between said inner edge and said substrate.

Claim 2. (Currently Amended) The apparatus of claim 1, wherein said apparatus comprises a susceptor for [[a]] holding said substrate.

Claim 3. (Original) The apparatus of claim 1, wherein said projections have a “C” shape.

Claim 4. (Original) The apparatus of claim 1, wherein said projections maintain a gap between a sidewall of said substrate and said inner edge.

Claim 5. (Original) The apparatus of claim 1, wherein said acute angle comprises an angle between 80 and 85 degrees.

Claim 6. (Original) The apparatus of claim 1, wherein said projections prevent said substrate from moving within said pocket.

Claim 7. (Currently Amended) An apparatus for holding a substrate, said apparatus comprising:
a pocket adapted to hold said substrate, wherein said pocket ~~has~~ comprises an inner edge
and a lower surface; and
a plurality of projections extending radially inward from said inner edge[~~[,]~~]; and
an opening in said lower surface;
wherein said projections have a beveled edge.

Claim 8. (Original) The apparatus in claim 7, wherein an acute angle occurs between a lower surface of said pocket and said beveled edge.

Claim 9. (Original) The apparatus in claim 7, wherein said projections reduce an area of contact between said inner edge and said substrate.

Claim 10. (Currently Amended) The apparatus of claim 7, wherein said apparatus comprises a susceptor for ~~[[a]]~~ holding said substrate.

Claim 11. (Original) The apparatus of claim 7, wherein said projections have a “C” shape.

Claim 12. (Original) The apparatus of claim 7, wherein said projections maintain a gap between a sidewall of said substrate and said inner edge.

Claim 13. (Original) The apparatus of claim 8, wherein said acute angle comprises an angle between 80 and 85 degrees.

Claim 14. (Original) The apparatus of claim 7, wherein said projections prevent said substrate from moving within said pocket.

Claim 15. (Currently Amended) A susceptor for holding a wafer, said susceptor comprising:

a pocket adapted to hold said wafer, wherein said pocket ~~has~~ comprises an inner edge;

and

a plurality of projections extending radially inward from said inner edge[~~,~~]; and

a device positioned below said pocket, said device being configured for lifting said wafer from said pocket;

wherein said projections have a beveled edge.

Claim 16. (Original) The susceptor in claim 15, wherein an acute angle occurs between a lower surface of said pocket and said beveled edge.

Claim 17. (Original) The susceptor of claim 16, wherein said acute angle is between 80 and 85 degrees.

Claim 18. (Original) The susceptor of claim 17, wherein said projections have a "C" shape.